

Number	Hits	Search text	DB	Time stamp
1	31	ammonia or "NH.sub.3") same ("methyl fluoride" or "CH.sub.3F")	USPAT; EPO; JPO; IBM_TDB	2002/11/10 12:13
3	12	ammonia or "NH.sub.3") and ("methyl fluoride" or "CH.sub.3F") and etch\$5	USPAT; EPO; JPO; IBM_TDB	2002/11/10 12:13
4	8952	ammonia or "NH.sub.3") same etch\$5	USPAT; EPO; JPO; IBM_TDB	2002/11/10 11:56
5	12	ammonia or "NH.sub.3") same etch\$5; same "low k"	USPAT; EPO; JPO; IBM_TDB	2002/11/10 12:02
6	88	ammonia or "NH.sub.3") same etch\$5; and "low k"	USPAT; EPO; JPO; IBM_TDB	2002/11/10 12:03
8	154	ammonia or "NH.sub.3") same ("methyl fluoride" or "CHF.sub.3") and etch\$5	USPAT; EPO; JPO; IBM_TDB	2002/11/10 12:38
9	5	("CF.sub.4" or CF4 or "carbon tetrafluoromethane") same ("C.sub.4F.sub.8" or C4F8 or octofluorocyclobutane) same (oxygen or "O.sub.2")	USPAT; EPO; JPO; IBM_TDB	2002/11/10 13:59
10	21	("CF.sub.4" or CF4 or "carbon tetrafluoromethane") and ("C.sub.4F.sub.8" or C4F8 or octofluorocyclobutane) and (oxygen or "O.sub.2")	USPAT; EPO; JPO; IBM_TDB	2002/11/10 13:19
7	236	ammonia or "NH.sub.3") same ("methyl fluoride" or "CHF.sub.3")	USPAT; EPO; JPO; IBM_TDB	2002/11/10 13:13
11	7170	("silicon oxide" or SiO) same organic	USPAT; EPO; JPO; IBM_TDB	2002/11/10 13:14
12	78	("silicon oxide" or SiO) same "organic dielectric"	USPAT; EPO; JPO; IBM_TDB	2002/11/10 13:17
13	9985	(parylene or polyether or polyimide) same etch\$5	USPAT; EPO; JPO; IBM_TDB	2002/11/10 13:20
14	956	("CF.sub.4" or CF4 or "carbon tetrafluoromethane") and ((parylene or polyether or polyimide) same etch\$5)	USPAT; EPO; JPO; IBM_TDB	2002/11/10 13:19
16	76	(parylene or polyether or polyimide) same etch\$5 same fluorocarbons	USPAT; EPO; JPO; IBM_TDB	2002/11/10 13:27
17	1	6080529.pn.	USPAT; EPO; JPO; IBM_TDB	2002/11/10 13:27
18	486	"low k" same etch\$5	USPAT; EPO; JPO; IBM_TDB	2002/11/10 13:42
19	1	("CF.sub.4" or CF4 or "carbon tetrafluoromethane") same ("C.sub.4F.sub.8" or C4F8 or octofluorocyclobutane) same "low k"	USPAT; EPO; JPO; IBM_TDB	2002/11/10 13:59
20	21	("CF.sub.4" or CF4 or "carbon tetrafluoromethane") and ("C.sub.4F.sub.8" or C4F8 or octofluorocyclobutane) and (oxygen or "O.sub.2")	USPAT; EPO; JPO; IBM_TDB	2002/11/10 14:07